

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PATENT

#5/Election
- Anot.R

Applicant:

Zheng et al.

Examiner:

Andujar, L.

Serial No.:

09/775,370

Group Art Unit:

2826

Filed:

February 1, 2001

Docket No.:

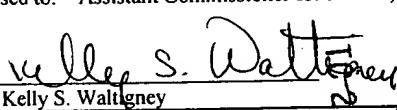
VLSI.225DIV1

Title:

OPTIMIZED METAL ETCH PROCESS TO ENABLE THE USE OF
ALUMINUM PLUGS

1-29-02
mew

CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this communication is being deposited in the United States Postal Service, as first class mail, in an envelope addressed to: Assistant Commissioner for Patents, Washington, D.C. 20231, on December 20, 2001.

By: 
Kelly S. Waltigney

JAN 28 2002
800 MAIL ROOM

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RESPONSE TO RESTRICTION REQUIREMENT

Assistant Commissioner for Patents
Washington, D.C. 20231

Sir:

In response to the Non-Final Office Action dated November 30, 2001 in which a restriction requirement was made, the claims of Group I (27-37) are hereby elected, without traverse. Please cancel claims 38-46.

Reconsideration and withdrawal of the restriction requirement is respectfully requested. If the Examiner has any questions or comments, a telephone call to the number indicated below is invited.

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By: 
Name: Robert J. Crawford
Reg. No.: 32,122